Computational Microelectronics Report (Homework #3)

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1. Specification

Figure 1 shows the structure of the epi-layer I am researching. In case of layer 4,5, the problem was solved. Thus, it is essential to specify the thickness and the relative permittivity of each layer, as mobile carriers are ignored. It is stated in Table 1.

a. Layer Structure							
Layer #	Layer Materials	Thickness	Composition	Doping	Note		
		(nm)					
5	GaN	2	-	Undoped			
4	$AI_xGa_{1-x}N$	27	x=0.22	-			
3	GaN Channel	300	-	Undoped			
2	GaN Buffer	4000	-	Fe			
1	AIN Nucleation	300	-	-			
Substrate	Si						

Figure 1. GaN HEMT Layer structure

Table 1. Thickness and relative permittivity of each layer

	GaN	AlGaN
Thickness (unit: nm)	2	27
Relative permittivity	8.9	8.8

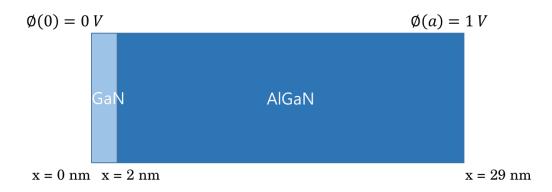


Figure 2. Two dielectric layers

2. Captured code

```
HW3.m × +
 1 -
        t1 = 2*10^-9; % GaN thickness (unit: m)
 2 -
        t2 = 27*10^-9; % AlGaN thickness (unit: m)
 3 -
        e1 = 8.9*8.854*10^-12; % GaN permittivity (unit: F/m)
 4 -
        e2 = 8.8*8.854*10^{-12}; % AlGaN permittivity (unit: F/m)
 5
 6 -
        T1 = t1/10^-9;
 7 -
        T2 = t2/10^-9;
 8 -
        N = T1+T2+1; % Point values
 9
10
        % Matrix form for approximation %
11 -
        A = zeros(N,N);
12 -
       A(1,1) = 1; A(N,N) = 1;
13 -
       A(2,1) = e1; A(2,2) = -2*e1; A(2,3) = e1;
14 -
        A(3,2) = e1; A(3,3) = -e2-e1; A(3,4) = e2;
15 - \Box \text{ for } i = 4:N-1
16 -
            A(i, i-1) = e2;
17 -
            A(i,i) = -2*e2;
18 -
            A(i,i+1) = e2;
19 -
      Lend
20
21 -
       b = zeros(N,1); b(N,1) = 1;
22 -
       x = inv(A)*b;
23 -
        Vmatrix = x(3,1); % Result
24
25 -
        a = [0:N-1];
26 -
        stem(a,x);
27 -
        xlabel('Distance (nm)');
28 -
        ylabel('Electric potential (V)');
29
30 -
        C1 = e1/t1;
31 -
        C2 = e2/t2;
32 -
        Vformular = C2/(C1+C2); % Analytic solution
33
        Error = (abs(Vmatrix - Vformular))/Vformular*100; % Comparision (error)
34 -
```

Figure 3. Captured code

3. Result

C1 =
$$3.94 \times 10^{-2} \text{ F/m}^2$$
 C2 = $2.88 \times 10^{-3} \text{ F/m}^2$

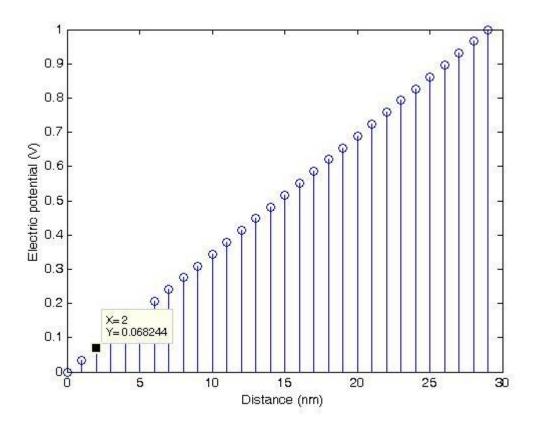


Figure 4. Electric potential - distance graph

Table 2. Comparison of result and solution / error

<u>Result</u>			Analytic solution			
	>> Vmatrix		>> Vformular			
	Vmatrix =		Vformular =			
	0.0682		0.0682			
	0.0682 V		0.0682 V			
Error						
	>> Error					
Error =						
1.0168e-13						
$2.30 \times 10^{-6}\%$						

The relative error between the result and the analytic expression is 2.30×10^{-6} %.